

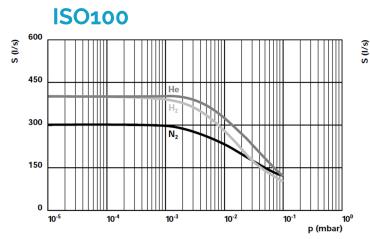
Pfeiffer TMH-521P, TMU-521P Technical Specifications

		TMH/U 521 P	TMH/U 521 P
Connection nominal diameter			
Input		DN 100 ISO-K	DN 160 ISO-KF
		DN 100 CF-F	DN 160 CF-F
Output		DN 25 ISO-KF	DN 25 ISO-KF
Pumping speed for			
Nitrogen N ₂	l/s	300	500
Helium He	l/s	400	500
Hydrogen H ₂	l/s	400	480
Compression ratio for			
Nitrogen N ₂		> 1 · 10 ¹²	$> 1 \cdot 10^{12}$
Helium He		5 · 10 ⁷	5 · 10 ⁷
Hydrogen H ₂		5 · 10 ⁶	5 · 10 ⁶
Fore vacuum pressure max.			
Nitrogen N ₂	mbar	12.5	12.5
Gas throughput			
Nitrogen N ₂	mbar I/s	12	12
Helium He	mbar I/s	12	12
Hydrogen H ₂	mbar I/s	10	10
Recommended backing pump			
Diaphragm pump		MVP 055-3	MVP 055-3
Rotary vane pump		DUO 5	DUO 5
Dry three-stage backing pump		-	-
Ultimate pressure TMH	mbar	< 1 · 10 ⁻⁸	< 1 · 10 ⁻⁸
Ultimate pressure TMU	mbar	< 5 · 10 ⁻¹⁰	< 5 · 10 ⁻¹⁰
Run-up time	min	5	5
Cooling			
Cooling standard		Air/Water	Air/Water
Weight	kg	14.5/15	13.5/14.5

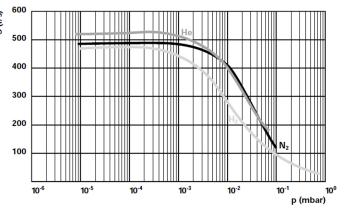
PROVAC SALES, INC. 3131 SOQUEL DRIVE, SOQUEL CA 95073



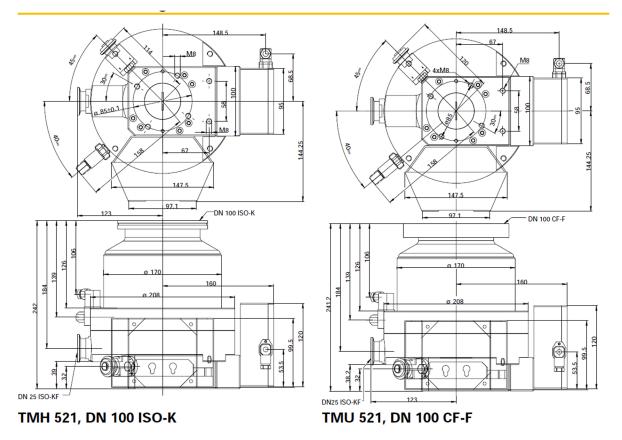
Pfeiffer TMH-521P, TMU-521P Pumping Curves



ISO160



Dimensions



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Pfeiffer TMH-521P, TMU-521P

Features & Benefits

- pump and drive form single unit
- simple and economical system solution
- modular design for maximum flexibility
- all components connects on the plug & play principle
- minimal space requirements for the entire system
- integrated serial interface provides additional versatility
- low vibration and noise level
- low system costs

Applications

- semiconductor processes thin film coatings mass spectrometry
- process gas monitors research & development accelerators
- vacuum processing
 UHV technology
 HV technology
 fusion

Recommended controller/backing pump

- Diaphgragm pumps: MVP 055-3
- Vane pumps: DUO 5 DUO 10
- Controllers: DCU-001 DCU-300